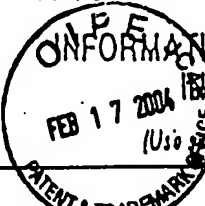


Form PTO-1449



INFORMATION DISCLOSURE CITATION
 IN AN APPLICATION
 (Use of prior art is necessary)

Document Number (Sequence)

TSMC-02-622

Application Number

10/718,877

Applicant

Shih-Wei Wang et al.

Filing Date

11/21/03

Group Art Unit

U. S. PATENT DOCUMENTS

| EXAMINER INITIAL | DOCUMENT NUMBER | DATE | NAME | CLASS | SUBCLASS | FILED DATE IF APPROPRIATE |
|---------------------|-----------------|----------|------------------|-------|----------|------------------------------|
| KR | 6417046 | 7/9/02 | Ho et al. | 438 | 257 | 5/5/00 |
| | 6184088 | 2/6/01 | Kurooka et al. | 438 | 264 | 2/25/99 |
| | 6268624 | 7/31/01 | Sobek et al. | 257 | 321 | 7/31/99 |
| | 5966606 | 10/12/99 | Ono | 438 | 303 | 5/14/97 |
| KR | 5827769 | 10/27/98 | Aminzadeh et al. | 438 | 305 | 11/20/96 |
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FOREIGN PATENT DOCUMENTS

| | DOCUMENT NUMBER | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
|--|-----------------|------|---------|-------|----------|-------------|----|
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OTHER DOCUMENTS (Including Author, Title, Date, Portion of Pages, Etc.)

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EXAMINER

DATE CONSIDERED

4/7/05

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